

**Final Exam, Fall 2006**

*ECSE-6968 – Physical Foundations of Solid-State Devices*

- Note:** (i) Put your name on paper, show your work, underline results, and always show units.  
(ii) Textbook, manuscript, excerpts, and calculators are allowed.

- The composition  $x$  of an  $\text{Al}_x\text{Ga}_{1-x}\text{As}$  layer is graded from  $x = 0$  to 0.30 over a distance of 500 nm. Assume that the bandgap energy varies with composition according to  $E_g = 1.424 \text{ eV} + 1.247 x \text{ eV}$  and that 2/3 of the band discontinuity occur in the conduction band.
  - What is the quasi-electric field in the composition-graded region?
  - How long would it take an electron with mobility of  $2000 \text{ cm}^2/\text{Vs}$  to traverse the graded region?
  - What is the diffusion constant of the electrons at 300 K?
  - What is the time needed for carriers to diffuse over the thickness of the graded region?
- The measured electron mobility in a selectively doped  $\text{Al}_x\text{Ga}_{1-x}\text{N}/\text{GaN}$  heterostructure at room temperature is  $1800 \text{ cm}^2/\text{Vs}$ . An equivalent uniformly doped GaN sample has a mobility of  $600 \text{ cm}^2/\text{Vs}$ . Answer the following questions; explain your conclusions.
  - What is the ionized impurity scattering mobility in the two structures?
  - Which scattering mechanism dominates for the two structures?
  - Assuming  $T \rightarrow \infty$ , which scattering mechanism will dominate for the two structures?
  - Assuming  $T \rightarrow 0$ , which scattering mechanism will dominate for the two structures?
- How would the electron density,  $n_{2\text{DEG}}$ , in a selectively doped  $\text{Al}_x\text{Ga}_{1-x}\text{N}/\text{GaN}$  heterostructure change when ...
  - ... increasing the Al content in  $\text{Al}_x\text{Ga}_{1-x}\text{N}$ ?
  - ... increasing the doping concentration?
  - ... increasing the spacer layer thickness?
  - ... increasing  $\Delta E_C$ ?
- An electron with effective mass  $m^* = 0.45 m_0$  tunnels through a barrier that is  $U_0 = 50 \text{ meV}$  high. Due to a design requirement, the tunneling probability must be  $10^{-6}$  or less.
  - Calculate the minimum barrier thickness  $L_B$  (give numerical value).
  - Give a formula that describes the tunneling probability through a rectangular barrier.
  - Write the formula in the following form:  $T = \exp(-L_B/L_e)$ .
  - Can you explain the physical meaning of  $L_e$ ?
  - Calculate  $L_e$  (give mathematical formula and numerical value).
- Consider electrons and holes in a quantum well (QW) structure. The Hamiltonian operator of an optical transition has the form  $H'(x) = e \mathcal{E}x$ .
  - What is the symmetry of p-orbital-like valence band states and s-orbital-like conduction band states?
  - Which of the QW electron states,  $E_{0e}, E_{1e}, E_{2e}, E_{3e}$ , has even symmetry?
  - Which of the QW hole states,  $E_{0h}, E_{1h}, E_{2h}, E_{3h}$ , has even symmetry?
  - What is the symmetry (even or odd symmetry) of the hamiltonian operator of an optical transition?
  - Which interband (conduction-to-valence-band) transitions are possible for an electron in the  $E_{0e}$  state?
  - Which intraband (within conduction band) transitions are possible for an electron in the  $E_{0e}$  state?
  - Do the answers to (e) and (f) change in the presence of a static electric field? Explain your answer.